

In re application of

Confirmation No. 4981

Hiroshi TAKANASHI et al.

Docket No. 2000-1749

Serial No. 09/739,750

Group Art Unit 1752

Filed December 20, 2000

Examiner S. Lee

NEGATIVE-WORKING PHOTOSENSITIVE RESIN COMPOSITION AND PHOTOSENSITIVE RESIN PLATE USING THE SAME THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT ACCOUNT NO. 23-0975

## **PETITION FOR EXTENSION OF TIME**

Assistant Commissioner for Patents, Washington, DC 20231

Sir:

Petition hereby is made for a two month extension of time to respond to the communication of June 19, 2002.

The fee of \$400.00 is

- (X) submitted herewith.
- () to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.
- () Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which
  - () is enclosed.
  - () has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

11/20/2002 JBALINAN 00000039 09739750

01 FC:1252

400.00 DP

Matthew Jacob

Registration No.25,154

Attorney for Applicants

MJ/jef

Washington, D.C. 20006-1021 Telephone (202) 721-8200

Facsimile (202) 721-8250

November 19, 2002